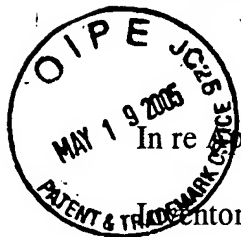


Docket No.: 2336-179

IPW/8
PATENT CC



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Inventor(s): SEO, Dong Hwan *et al.*

U.S. Patent Application No. 10/601,776

Filed: June 24, 2003

:
:
: Confirmation No. 9501
:
: Group Art Unit: 1755
: Allowed: March 1, 2005
: Examiner: Karl E. Group

For: LOW TEMPERATURE SINTERABLE DIELECTRIC CERAMIC COMPOSITION,
MULTILAYER CERAMIC CHIP CAPACITOR AND CERAMIC ELECTRONIC
DEVICE

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached form PTO-1449. It is respectfully requested that the documents be expressly considered during the prosecution of this application, and that the documents be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed more than three months after the U.S. filing date and after the mailing date of a Final Rejection or Notice of Allowance, but before payment of the Issue Fee.

CERTIFICATION PARAGRAPH

The undersigned hereby certifies that each item of information contained in this

information disclosure statement was first cited in any communication from a foreign patent

05/20/2005 HALI11 00000053 10601776

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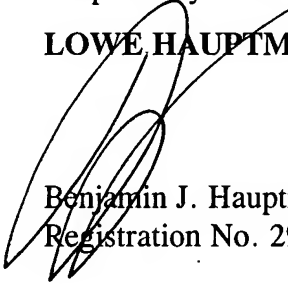
180.00 DP

office in a counterpart foreign application not more than three months prior to the filing of the information disclosure statement (37 CFR 1.97 (e)(1)).

A credit card authorization form in the amount of \$180.00 is attached. Any deficiency or overpayment should be charged or credited to Deposit Account No. 07-1337.

Respectfully submitted,

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Date: May 19, 2005

INFORMATION DISCLOSURE CITATION IN AN APPLICATION (PTO-1449)			ATTY. DOCKET NO. 2336-179		U.S. PATENT APPLICATION NO. 10/601,776		
			APPLICANT SEO, Dong Hwan <i>et al.</i>				
			FILING DATE June 24, 2003		GROUP 1755		
U.S. PATENT DOCUMENTS							
EXAMINER'S INITIALS	PATENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE	
FOREIGN PATENT DOCUMENTS							
EXAMINER'S INITIALS	PATENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	Abstract	
						Yes	No
	2000-327428	11-2000	Japan			X	
	2000-143332	05-2000	Japan			X	
OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)							
EXAMINER	---			DATE CONSIDERED			

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.